

Form 1449 (Modified) Information Disclosure Statement By Applicant (Use Several Sheets if Necessary)	Atty Docket No.	Application No.:
	NOVLP088/NVLS-2882	10/825,888
	Applicant:	
	Bandyopadhyay et al.	
Filing Date	Group	
April 16, 2004	2812	

U.S. Patent Documents

Examiner Initial	No.	Patent No.	Date	Patentee	Class	Sub-class	Filing Date
<i>JS</i>	B1	6,420,441	10/10/99	Allen et al. 7/2002			12/10/99
	B2	6,271,273	10/10/00	You et al. 7/2001			10/10/00
	B3	4,885,262	12/5/89	Ting et al. 12/1989			03/08/89
	B4	5,686,054	11/11/97	Barthel et al.			05/16/95
	B5	5,851,715	12/22/98	Barthel et al.			06/18/97
	B6	6,140,252	10/31/00	Cho et al.			05/05/98
	B7	6,392,017	5/21/02	Chandrashekar			08/04/00
	B8	6,386,466	5/14/02	Ozawa et al.			04/11/00
	B9	4,357,451	11/2/82	McDaniel			08/28/01
	B10	6,479,374	11/12/02	Ioka et al.			09/27/00
	B11	6,548,113	4/15/03	Birnbaum et al.			11/09/00
	B12	2002/0034626	03/21/02	Liu et al.			04/18/01
	B13	2002/0001973	01/03/02	Wu et al.			04/24/01

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6/4/01

Other Documents

Examiner Initial	No.	Author, Title, Date, Place (e.g. Journal) of Publication
<i>JS</i>	B14	Cho et al., "Plasma Treatments of Molecularly Templated Nanoporous Silica Films," Electrochemical and Solid-State Letters, 4 (4) G35-G38 (2001)
<i>JS</i>	B15	Yung et al., "Spin-on Mesoporous Silica Films with Ultralow Dielectric Constants, Ordered Pore Structures, and Hydrophobic Surfaces," Adv. Mater. 2001, 13, No. 14, 1099-1102
Examiner	Date Considered	
<i>JS</i>	6/24/06	

Examiner: Initial citation considered. Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant.